



00839.000419.1

## PATENT APPLICATION

IFW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: )  
MAKOTO HIGASHIKAWA ET AL. ) : Examiner: Maureen G. Arancibia  
Application No.: 10/656,130 ) : Group Art Unit: 1763  
Filed: September 8, 2003 ) :  
For: PROCESS FOR FORMING A )  
MICROCRYSTALLINE :  
SILICON SERIES THIN )  
FILM AND APPARATUS :  
SUITABLE FOR PRACTICING )  
SAID PROCESS : December 19, 2005

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

## AMENDMENT

Sir:

(a) Introductory Comments

In response to the Office Action dated September 20, 2005, kindly amend the subject application as follows: